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Ferroelectric phase transitions of antiferroelectric PbZrO_3 thin films

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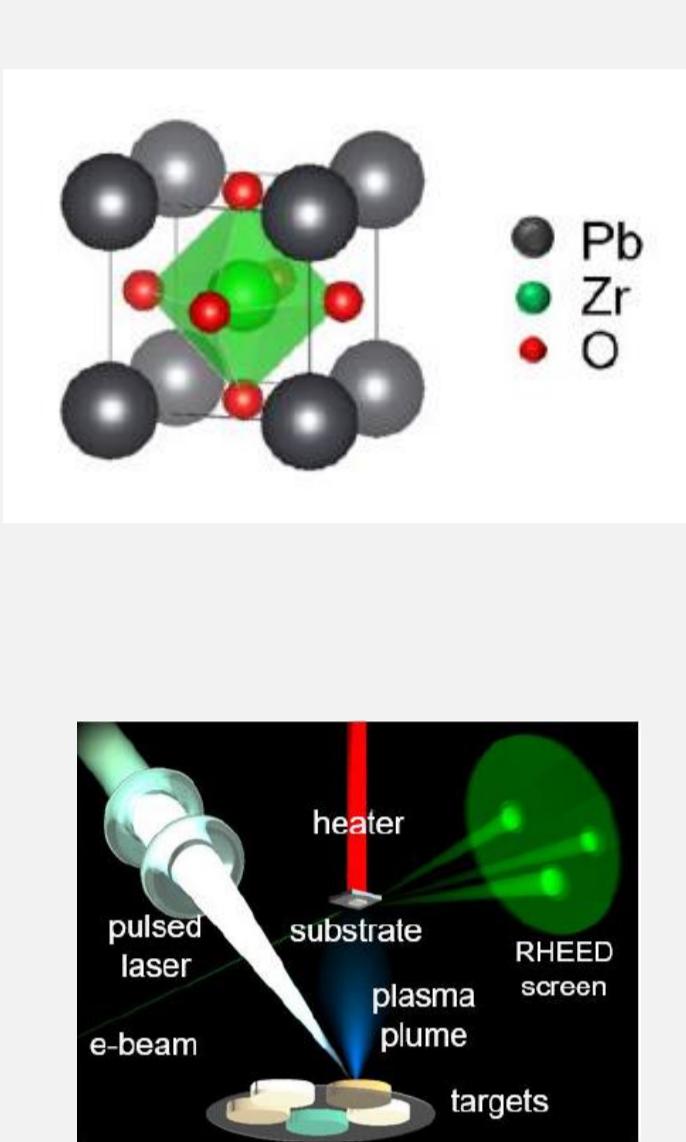
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Challenge and growth

The archetypical antiferroelectric, PbZrO_3 , is currently attracting a lot of interest, but no consensus can be clearly established on the nature of its ground state as well as on the influence of external stimuli over its physical properties. The debate is even more controversial in epitaxial thin films for which the epitaxial strain can affect the stabilization of the PbZrO_3 .

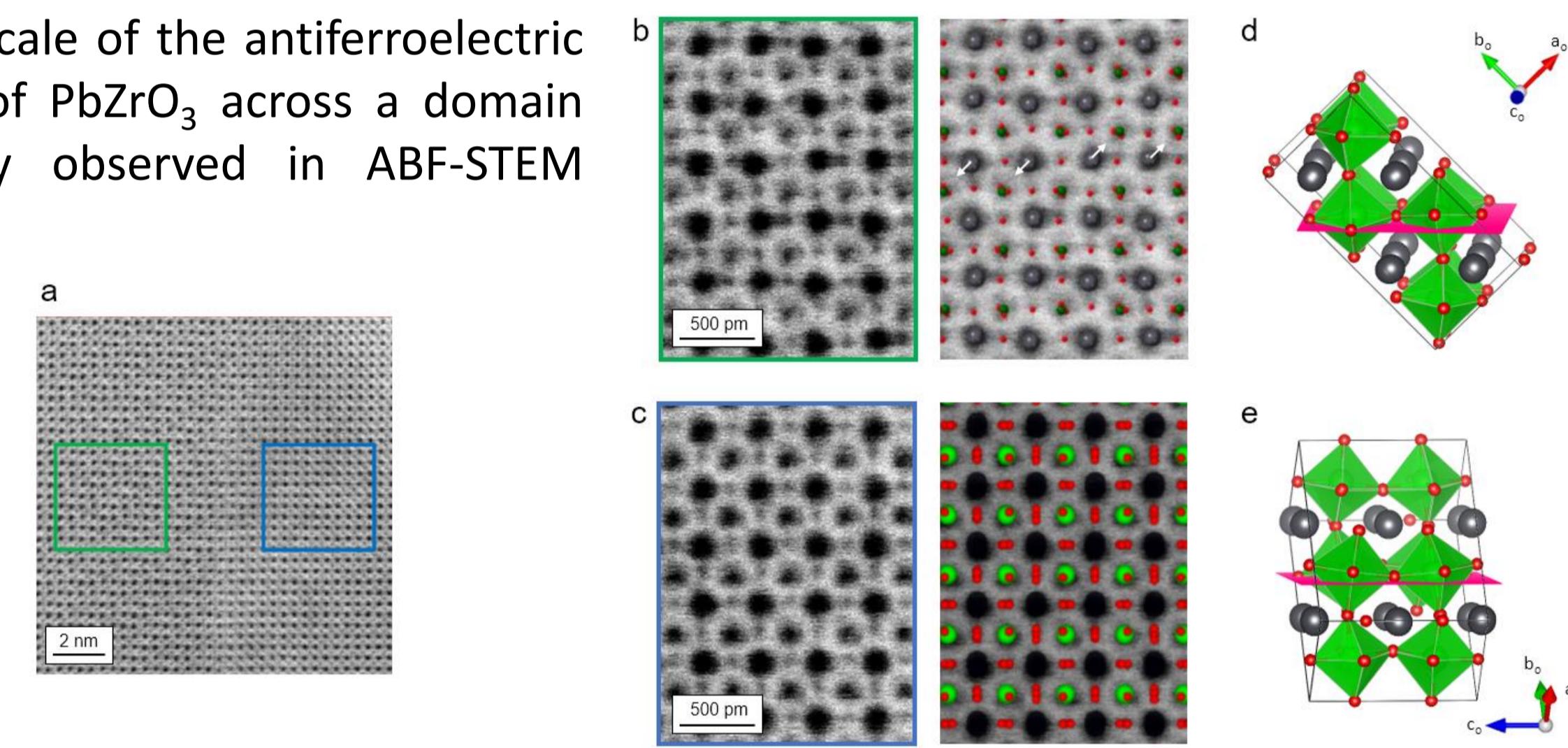
In this work, 45-nm-thick epitaxial PbZrO_3 thin films were grown by pulsed laser deposition on orthorhombic GdScO_3 (110)_o. To enable electric-field measurements, a pseudo-cubic $\text{Ba}_{0.5}\text{Sr}_{0.5}\text{RuO}_3$ thin film was grown as bottom oxide electrodes.



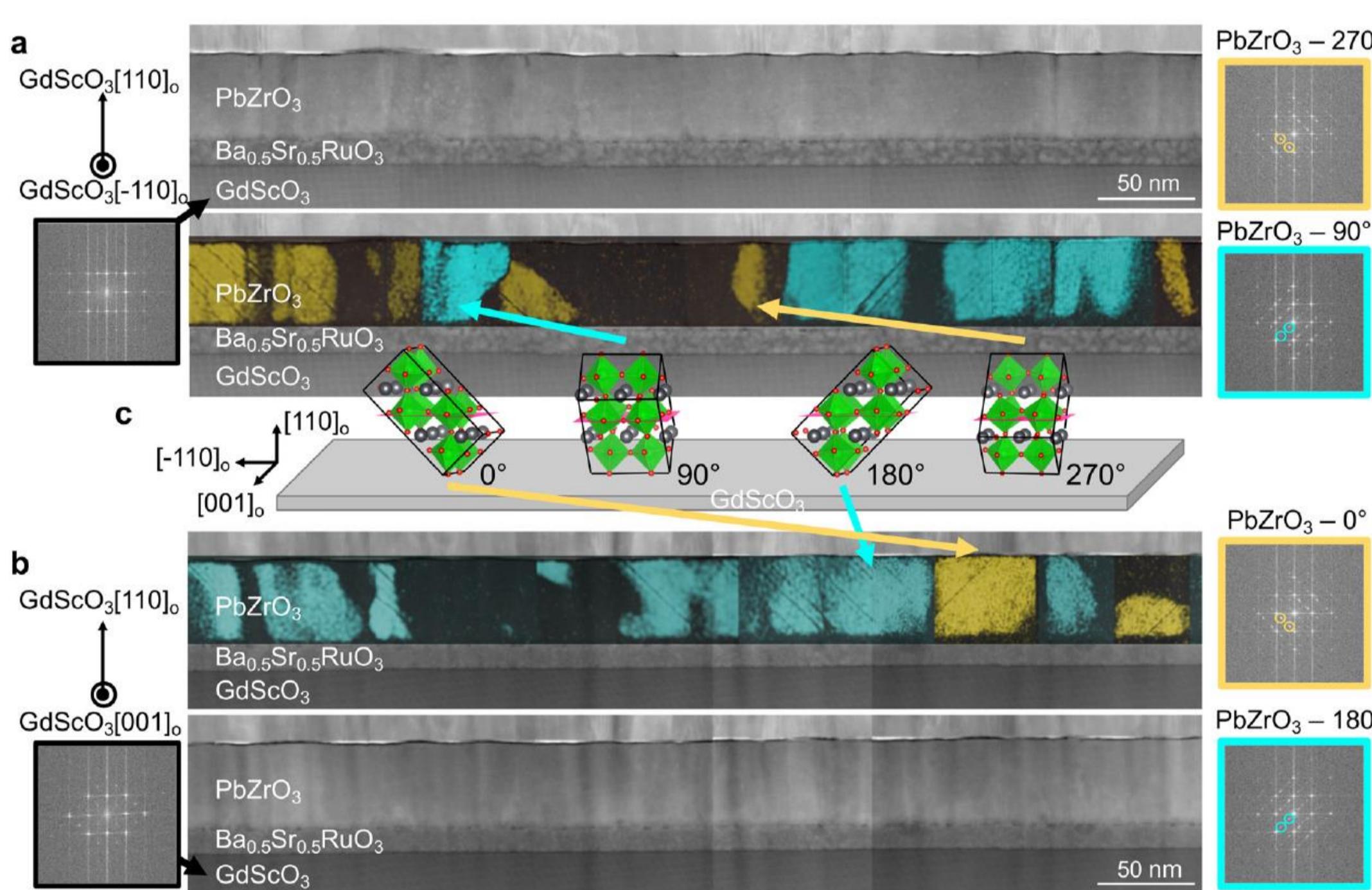
In situ atomic STEM monitoring of phase change as a function of the temperature

Room temperature analyses

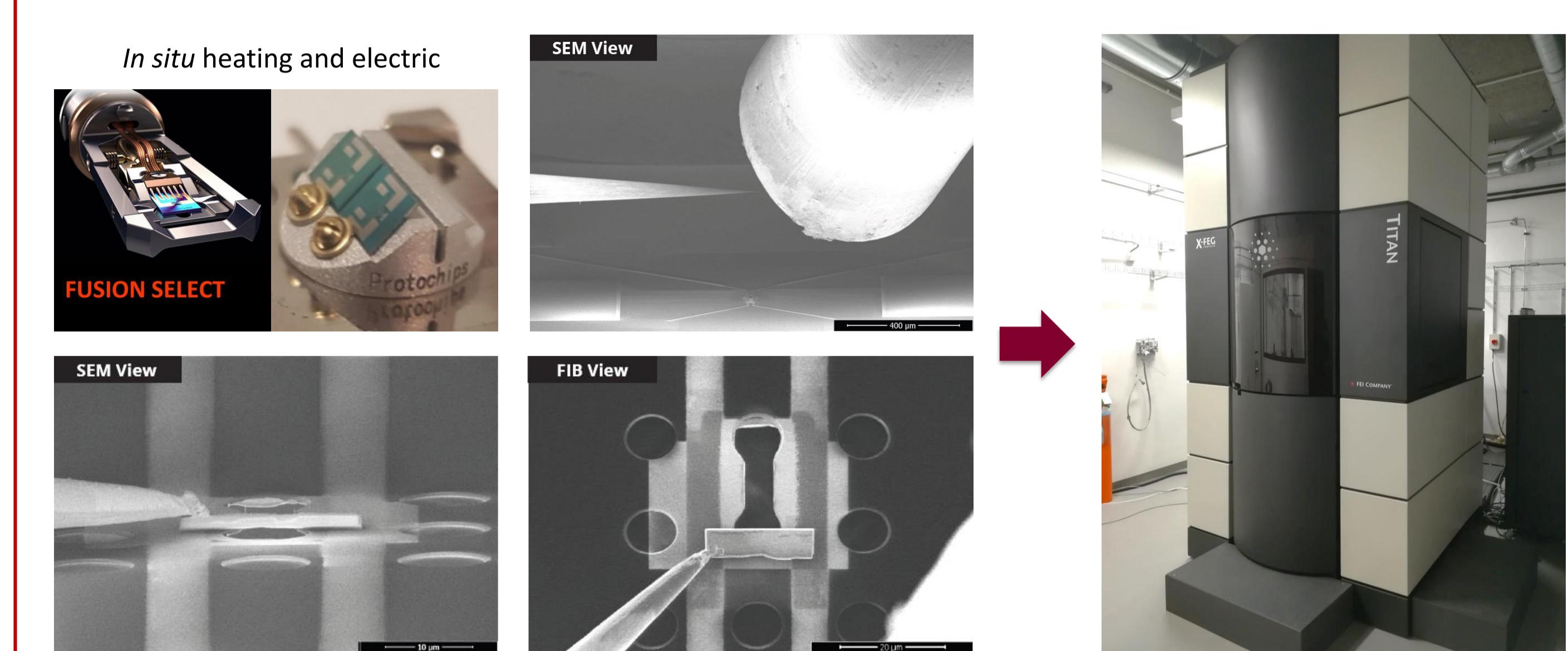
Atomic scale of the antiferroelectric feature of PbZrO_3 across a domain boundary observed in ABF-STEM mode



Statistical distribution of antiferroelectric domains along the two zone axes of GdScO_3 (110)_o substrate obtained from HAADF-STEM images

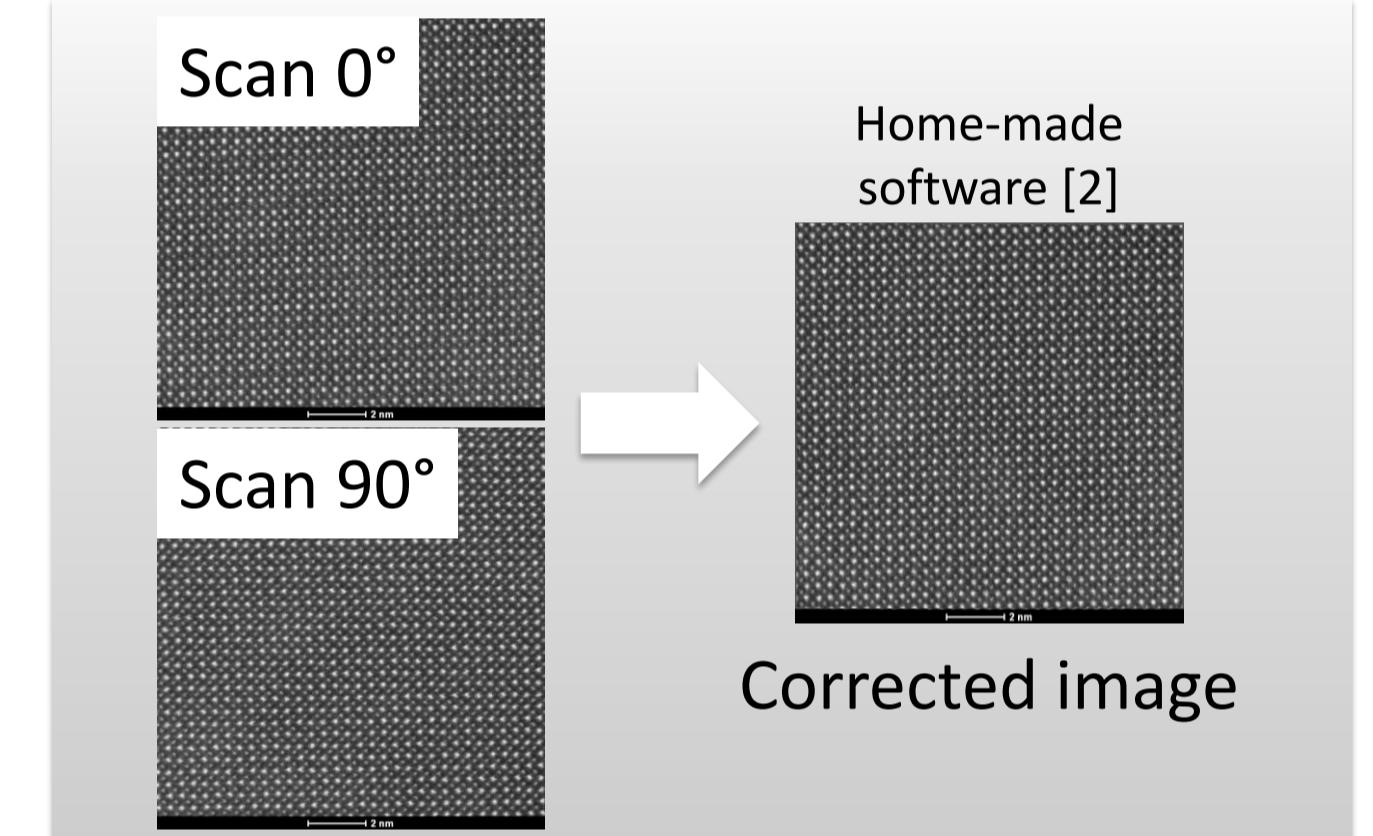
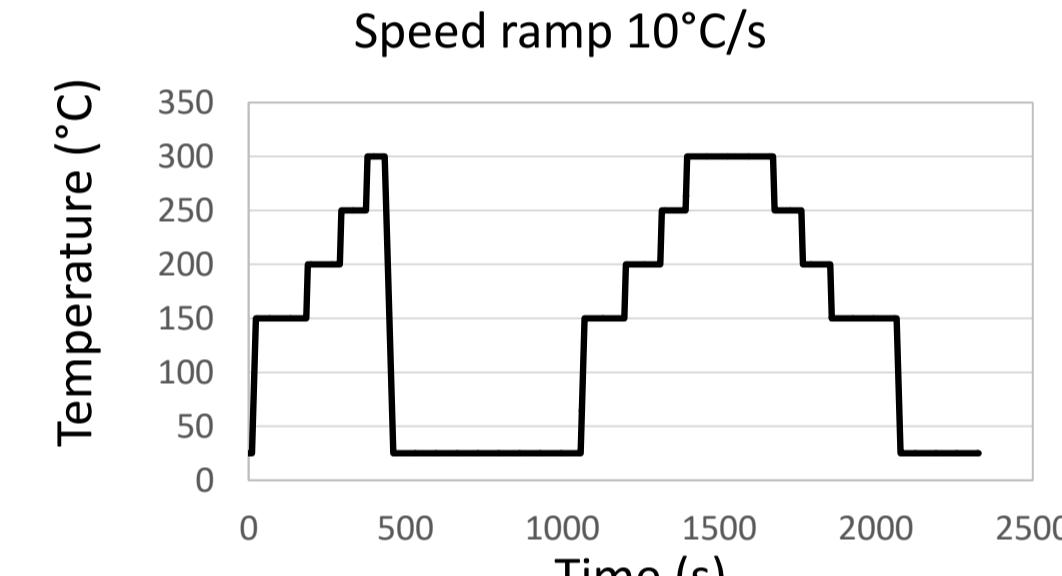


Sample preparation by FIB-SEM

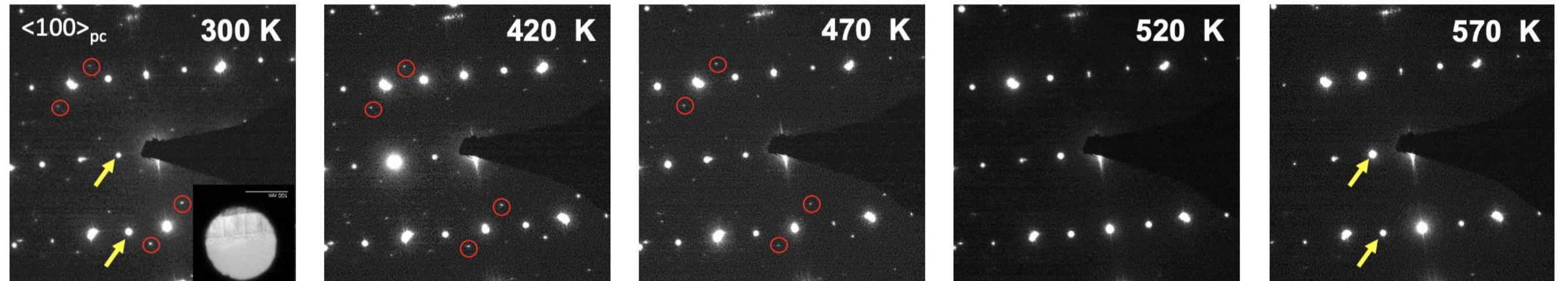


Temperature dependence on one domain

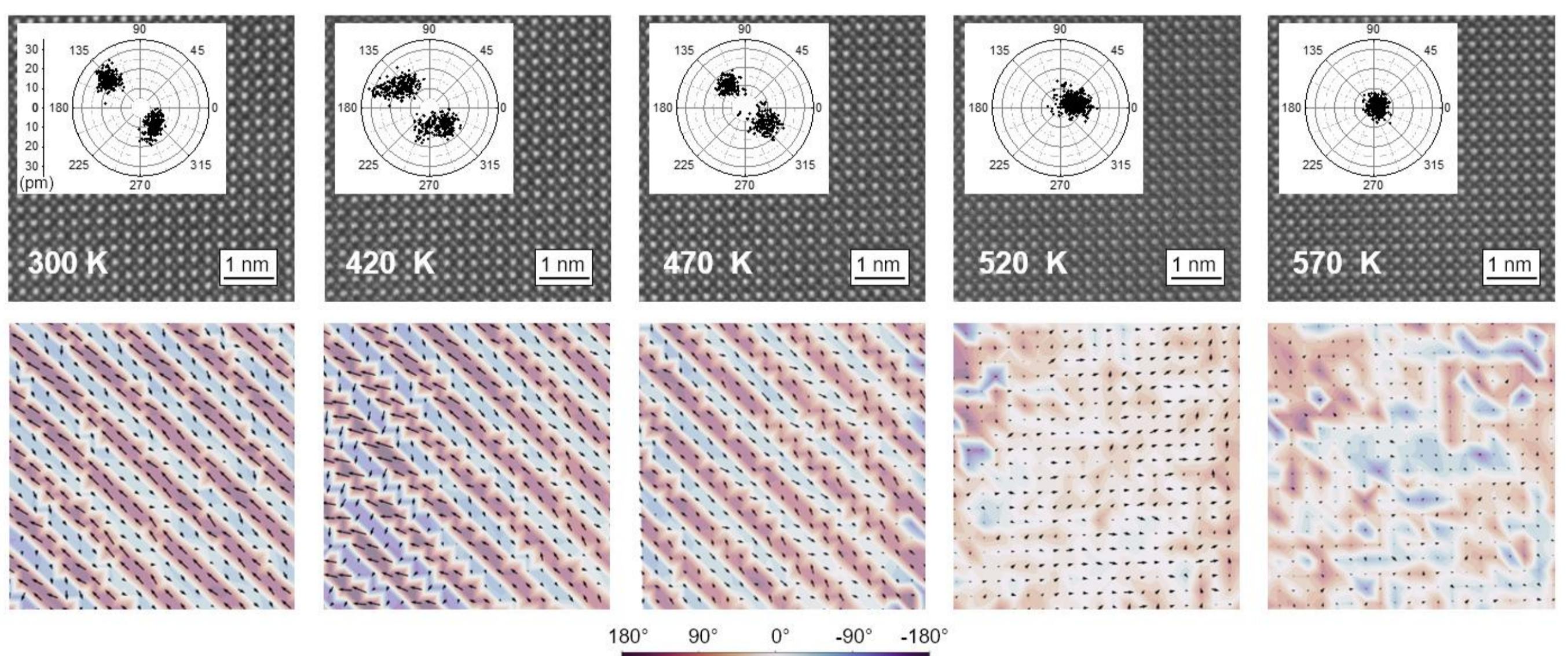
Heating up to 300°C along multiple cycles and different samples



Selected area electron diffraction: loss of diffraction spots from AFE periodicity



High resolution HAADF-STEM images of the same domain



Electrical measurements

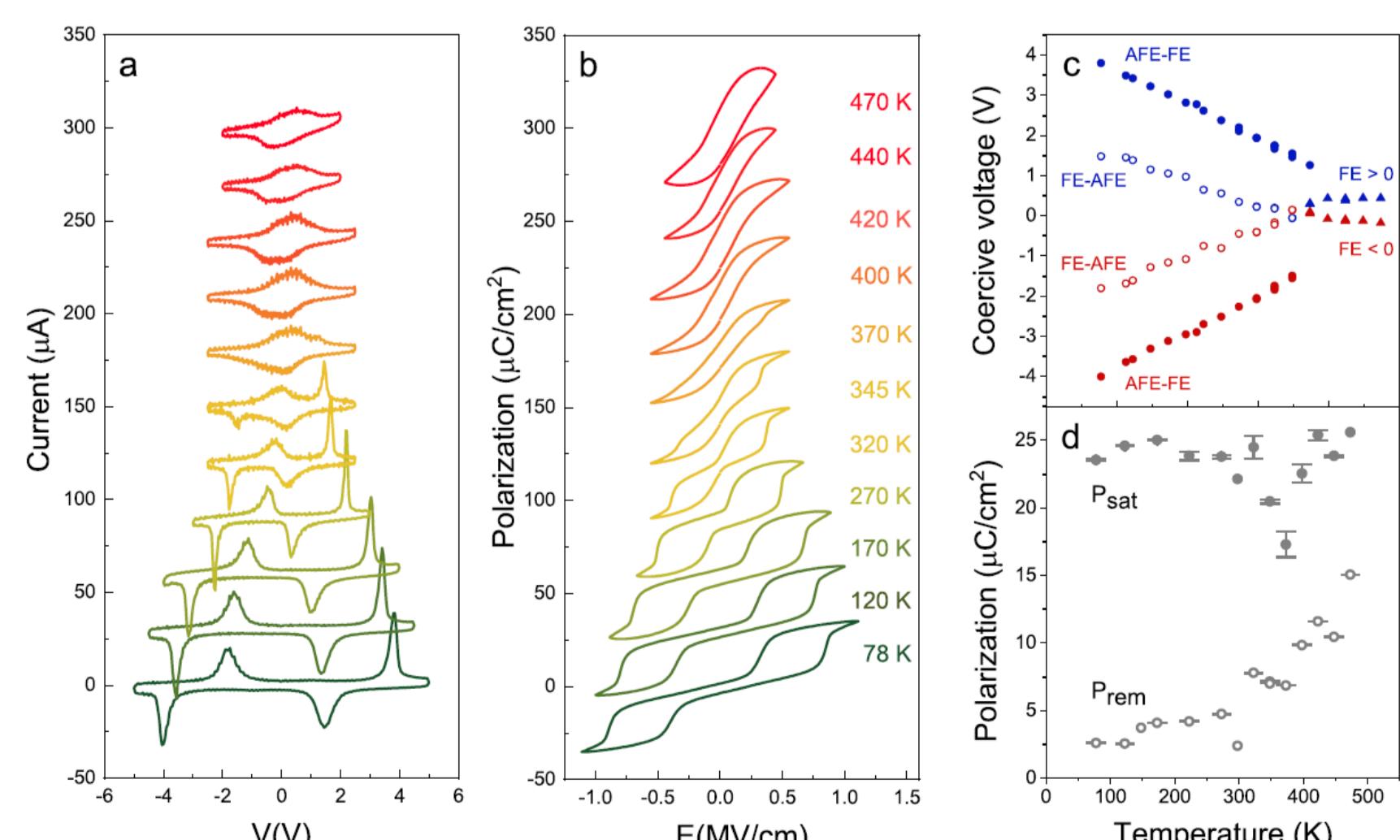


FIG. 6. Electric-field-induced phase transitions with increasing temperature. (a) I-V and (b) P-T loops of a 45-nm-thick PbZrO_3 film acquired at several temperatures ranging from 70 to 470 K at 1 Hz. The I-V and P-T loops are vertically shifted. (c) Evolution of the coercive voltage as a function of temperature. The blue circles correspond to the coercive voltages of the transition from an AFE to a FE state (solid circle) and its associated back-switching (open circle) for positive voltages. The red dots are their equivalent for negative bias. The triangles are the coercive voltages of the ferroelectric-like phase. (d) Temperature evolutions of the remnant polarization (P_{rem}) in open symbols and of the saturation polarization (P_{sat}) in solid symbols.

DFT-based calculations

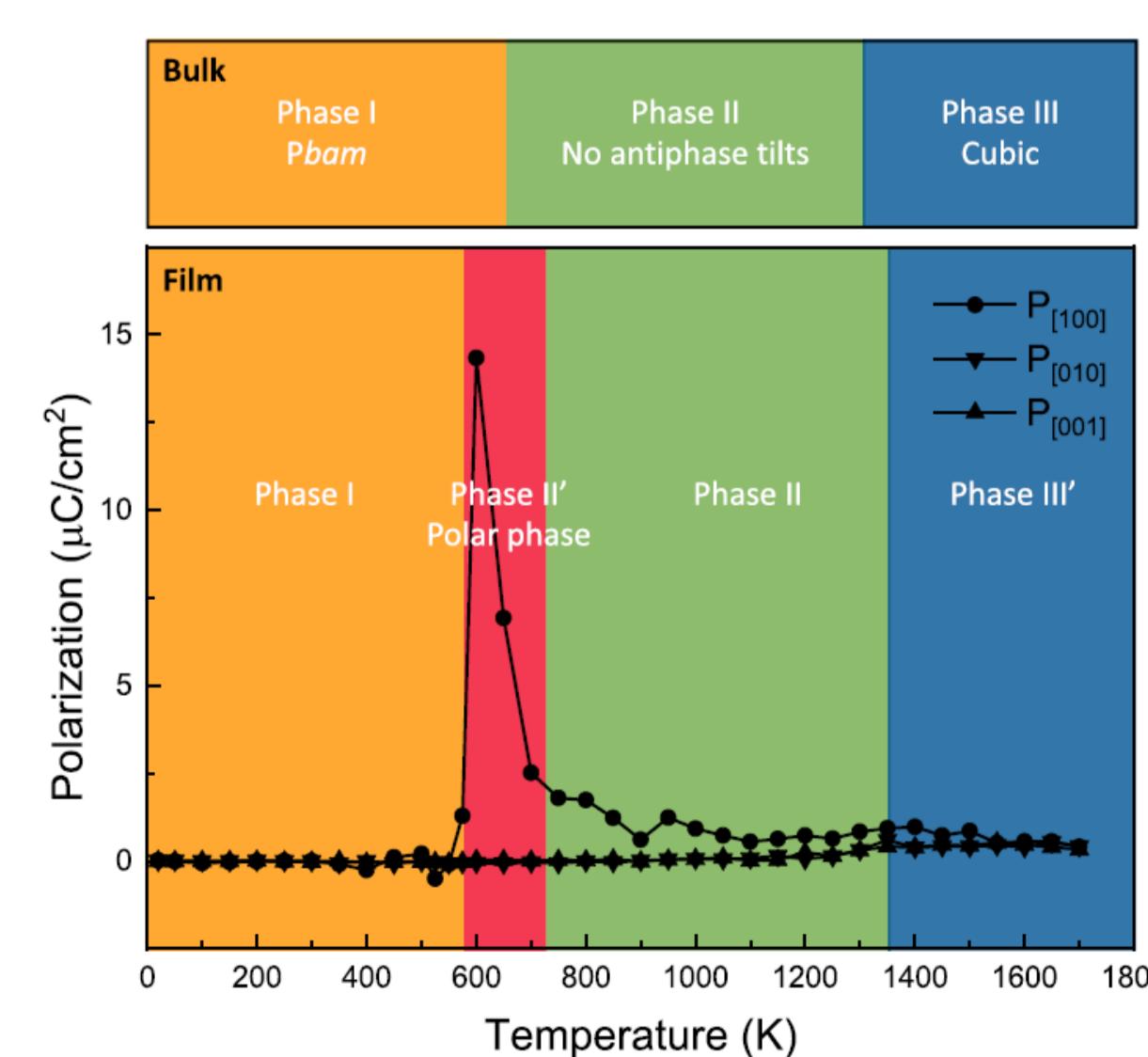


FIG. 8. Computed phase diagram of PbZrO_3 using atomic simulations. Calculated structural phases of PbZrO_3 as a function of temperature for bulk (top) and an epitaxial film with fixed in-plane parameters in the (001)_o plane (bottom). The computed polarizations and temperature along the in-plane (100)_o, (010)_o, and out-of-plane (001)_o directions are displayed for the film case.

Prediction of a ferroelectric phase with the epitaxial biaxial strain

Summary

- Direct evidence for the antiferroelectric behavior in 45-nm-thick epitaxial PbZrO_3 films at room temperature
- In situ* STEM observation of phase transition at the atomic scale up to 300°C.
- Observation of a ferroelectric-like phase in a large temperature window (100°C) in agreement with electrical measurements